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Erika L. Sesti, Jinlei Cui, Sophia E. Hayes, Mark S. Conradi

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## **ACCEPTED MANUSCRIPT**

# A flow-through, elevated-temperature and pressure NMR apparatus for in-situ CO<sub>2</sub> sequestration studies

Erika L. Sesti<sup>a</sup>, Jinlei Cui<sup>a</sup>, Sophia E. Hayes<sup>a</sup>, and Mark S. Conradi<sup>b,c</sup>

<sup>a</sup>Department of Chemistry, Washington University in St. Louis, St. Louis, MO 63130, United States <sup>b</sup>Department of Physics, Washington University in St. Louis, St. Louis, MO 63130, United States <sup>c</sup>ABQMR, 2301 Yale Blvd SE, Suite C2, Albuquerque, NM 87106, United States

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